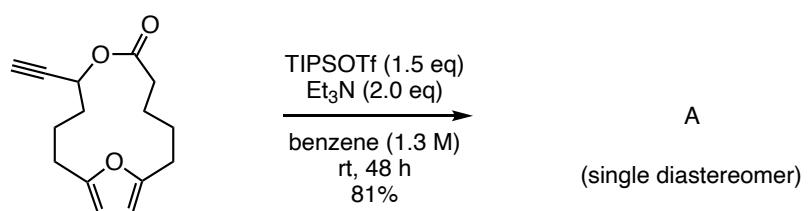
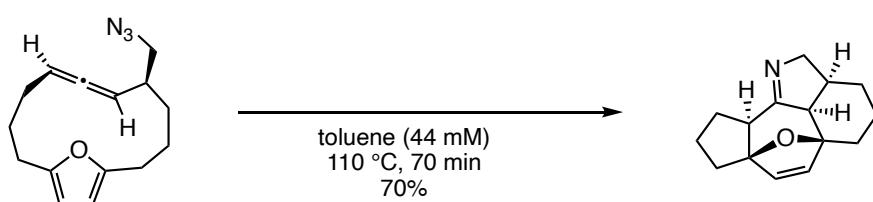


K. Kato, K. Ikeuchi, T. Suzuki, K. Tanino*
Org. Lett. ASAP, DOI: 10.1021/acs.orglett.2c02434



IR: 3101, 1958, 1715,
Chemical formula : $\text{C}_{24}\text{H}_{38}\text{O}_3\text{Si}$



J. Robertson* et al. *Org. Lett.* **2017**, *19*, 2174.